



Joint ISAF-ICE-EMF-IWPM-PFM conference - 2019 f²cπ²

<http://lausanne2019.org>

SwissTech Convention Center, EPFL, Lausanne, Switzerland

IEEE International Symposium on Applications of Ferroelectrics ISAF

European Meeting on Ferroelectricity EMF

International Workshop on PiezoMEMS IWPM

International Conference on ElectroCeramics ICE

Piezoresponse Force Microscopy Workshop PFM

Conference address: P. Muralt, EPFL, SCIO ST10 PM, Station 12, CH0 1015 Lausanne, Switzerland

email: paul.muralt@epfl.ch

Tel: +41 21 693 4957 / +41 693 2975

June 4, 2019

Prof. Yaojin Wang
Nanjing University of Science and Technology
200 Xiaolingwei, Nanjing, 210094
Nanjing Jiangsu 210094
China

Passport number PE1162708
Issued on 22 MAR 2017
Issued at NANJING

Dear Prof. Yaojin Wang,

On behalf of the Organizing and Program Committees, I have the great pleasure to inform you that your paper submitted to the Joint 2019 f²cπ² Conference has been accepted for presentation at the meeting. At least one author of your paper must register and attend the conference to present it. We hope that you will participate in this scientific meeting and help to make it a memorable event. Acceptance of your paper for presentation does not, in any way, financially oblige the conference organizers for the expenses incurred by you to travel and attend the conference. If you have any questions, please contact me.

The Joint 2019 f²cπ² Conference will be held Sunday through Friday, July 14-19, 2019, at the SwissTech Convention Center on the campus of EPFL (Ecole Polytechnique Fédérale de Lausanne) near the town of Lausanne, situated at Lake Geneva, Switzerland.

This international conference aims to bring together leaders from academia, national laboratories and industrial research and development sectors, to discuss the most recent advancements in the science and technology of ferroelectric, electroceramic, and dielectric materials, covering a broad range of fields from theory and modeling of the materials, via processing and characterization thereof, to the development of new applications and devices.

Please note: Depending on your citizenship, you may require a visa to enter Switzerland or Schengen space in Europe. For additional information about visa and travel authorization, please visit the corresponding website of our conference, or directly the web page of the Swiss Foreign Affairs:

<https://www.eda.admin.ch/eda/en/home/entry-switzerland-residence/visa-requirements-application-form.html>

Thank you in advance for your participation. I look forward to seeing you in Lausanne.

Sincerely yours,

Prof. Paul Muralt, General Chair

Accepted paper details:

Yaojin Wang, "Nonvolatile photoelectric memory based on ferroelectric-gated black phosphorus transistor." Scheduled for presentation on Friday July 19, 2019, 10:15-10:30 hrs.